



AF/2005

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/734,179
Filing Date: December 15, 2003
Applicant: Sang Kyun Lee et al.
Group Art Unit: 1712
Examiner: Margaret G. Moore
Title: Siloxane-Based Resin Containing Germanium and Interlayer Insulating Film for Semiconductor Device Made Using the Same
Attorney Docket: 6661-000038/US

OK for
entry
mgm 11/28/05

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop Amendment

November 17, 2005

AMENDMENT UNDER 37 C.F.R. § 1.116

Sir:

In response to the Final Office Action mailed August 31, 2005, please enter this Amendment and its remarks into the file of the above-identified application.

No fees are believed to be due for the filing of this Amendment. However, should any fees be required or an overpayment of fees made, please debit or credit our Deposit Account No. 08-0750, as necessary.

Amendments to the Claims begin on page 2 of this Amendment.

Remarks begin on page 4 of this Amendment.